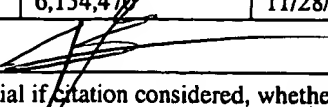


Form PTO 1449 (Rev. 2-32) U.S. Department of Commerce Patent and Trademark Office				Atty. Docket No. LMPY-11310		Serial No. 09/771,013	
Information Disclosure Statement by Applicant (Use several sheets if necessary)				Applicant: Klaus Vogler, et al.			
				Filed: January 25, 2001 Group: 2881			
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						Yes	No
PN	0 236 137 A2	3/5/87	EPO	G01J	3/45	X	
↓	63-86593	4/16/88	Japan	H01S	3/134	X	
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